ACTION: Notice of intent.

SUMMARY: In accordance with the President's Council of Environmental Quality (CEO) Rules and Regulations, as defined and amended in 40 Code of Federal Regulations (CFR), Parts 1500-1508, the U.S. Army Corps of Engineers (USACE), New York District (District), is preparing a Draft Environmental Impact Statement (DEIS) to determine the feasibility of implementing flood damage protection and aquatic ecosystem restoration measures along the Woodbridge River Basin in Middlesex, NJ. The Woodbridge River Basin (Basin) is approximately 5 miles in length with a drainage area of approximately 10 miles. Tidal surges and inadequate channel capacities to contain increased stormwater runoff account for flooding problems within the Basin. The Basin has experienced numerous flood events that have incurred damages to homes, businesses and pubic infrastructure; the latest occurring in October of 1996 during which the Township of Woodbridge sustained damages in excess of \$1 million. Direct impacts to the Basin's aquatic ecosystem as a result of urbanization include the loss of wetland acreage, floodplain encroachment, stream bank erosion, increased sedimentation and nutrient and pollutant loading. The District will develop and evaluate various structural and non-structural flood damage reduction measures and will investigate opportunities to restore aquatic ecosystem structure and functions.

FOR FURTHER INFORMATION CONTACT: Ms. Kimberly Rightler, Project Biologist, Planning Division, U.S. Army Corps of Engineers, New York District, NY 10278–0090, (212) 264–9846 or kimberly.a.rightler@usace.army.mil.

SUPPLEMENTARY INFORMATION:

1. This study is authorized by U.S. House of Representatives Resolution Docket 2552 dated May 1998.

2. Scoping: Public scoping meeting(s) are anticipated to occur in September 2003. Results from the public scoping meeting(s) with the District and Federal, state, and local agencies will be addressed in the DEIS. A separate notice, in local area newspapers, indicating the location, date and time of the scoping meeting(s) will be released at a later date and a scoping document will be prepared and made available prior to the scoping meeting(s). Parties interested in receiving notices of public scoping meeting(s) or copies of the scoping document should contact Ms. Rightler at the above address.

3. *Date of DEIS Release:* The DEIS is scheduled to be available April 2005.

Frank Santomauro,

Chief, Planning Division. [FR Doc. 03–15021 Filed 6–12–03; 8:45 am] BILLING CODE 3710–06–M

DEPARTMENT OF DEFENSE

Department of the Navy

Notice of Availability of Government-Owned Inventions; Available for Licensing

AGENCY: Department of the Navy, DOD.

ACTION: Notice.

SUMMARY: The inventions listed below are assigned to the United States Government as represented by the Secretary of the Navy and are available for licensing by the Department of the Navy. U.S. Patent No. 5,976,284: Patterned Conducting Polymer Surfaces and Process for Preparing the Same and Devices Containing the Same, Navy Case No. 78,825.//U.S. Patent No. 5,828,432: Conducting Substrate, Liquid Crystal Device Made Therefrom and Liquid Crystalline Composition in Contact Therewith, Navy Case No. 77,014.// Navy Case No. 84,102: Highly **Conducting Transparent Thin Polymers** Films Formed from Double and Multiple Layers of Poly(3,4 Ethylene Dioxythiophene) and its Perivatives.// Navy Case No. 84,103: Highly Conducting and Transparent Thin Films Formed from New Fluorinated Perivatives of 3,4 Ethylene Dioxythiophene.

ADDRESSES: Requests for copies of the inventions cited should be directed to the Naval Research Laboratory, Code 1004, 4555 Overlook Avenue, SW., Washington, DC 20375–5320, and must include the Navy Case number.

FOR FURTHER INFORMATION CONTACT:

Catherine M. Cotell,Ph.D., Head, Technology Transfer Office, NRL Code 1004,4555 Overlook Avenue, SW., Washington, DC 20375–5320, telephone (202) 767–7230. Due to temporary U.S. Postal Service delays, please fax (202) 404–7920, E-Mail: *cotell@nrl.navy.mil* or use courier delivery to expedite response.

(Authority: 35 U.S.C. 207, 37 CFR Part 404). Dated: June 9, 2003.

E.F. McDonnell,

Major, U.S. Marine Corps, Federal Register Liaison Officer.

[FR Doc. 03–14924 Filed 6–12–03; 8:45 am] BILLING CODE 3810–FF–P

DEPARTMENT OF DEFENSE

Department of the Navy

Notice of Intent To Grant Exclusive Patent License; Star Cyroelectronics

AGENCY: Department of the Navy, DOD. **ACTION:** Notice.

SUMMARY: The Department of the Navy hereby gives notice of its intent to grant to Star Cyroelectronics, a revocable, nonassignable, exclusive license in the United States to practice the Government-owned invention described in U.S. Patent No. 6,051,846 entitled "Monolithic Integrated High-Tc Superconductor-Semiconductor Structure" and U.S. Patent No. 6,165,801 entitled "Method for Making a Monolithic Integrated High-Tc Superconductor-Semiconductor Structure".

DATES: Anyone wishing to object to the granting of this license has (15) days from the date of this notice to file written objections along with supporting evidence, if any.

ADDRESSES: Written objections are to be filed with the Office of Patent Counsel, Space and Naval Warfare Systems Center, Code 20012, 53510 Silvergate Ave., Room 103, San Diego, CA 92152– 5765.

FOR FURTHER INFORMATION CONTACT: Mr. James A. Ward, Space and Naval Warfare Systems Center, Code 20012, 53510 Silvergate Ave, Room 103, San Diego, CA 92152–5765, telephone (619) 553–3823.

(Authority: 35 U.S.C. 207, 37 CFR part 404.7(a)).

Dated: June 4, 2003.

E.F. McDonnell,

Major, U.S. Marine Corps, Federal Register Liaison Officer. [FR Doc. 03–14906 Filed 6–12–03; 8:45 am]

BILLING CODE 3810-FF-P

DEPARTMENT OF EDUCATION

Office of Postsecondary Education; Strengthening Institutions (SIP), American Indian Tribally Controlled Colleges and Universities (TCCU), and Alaska Native and Native Hawaiian-Serving Institutions (ANNH) Programs; Developing Hispanic-Serving Institutions (HSIs) Program

AGENCY: Department of Education. **ACTION:** Notice reopening application deadline dates for certain applicants.

SUMMARY: The Secretary reopens the deadline dates for certain applications